(5) what is the concentration of hales in Si crystals having donor concentration of 1.4×10²⁴/2.m³ when the thinting carrier concentration is 1.4×10¹⁸/m³9. The thinting carrier concentration is 1.4×10¹⁸/m³9. Sol Intrinsic carrier concentration $n_i = 1.4 \times 10^{18}$ /m³ Donor concentration $N_D = 1.4 \times 10^{24}$ /m³ Concentration of electrons $n = N_D = 1.4 \times 10^{24}$ /m³ Concentration of hale $p = \frac{n_i^2}{n} = \frac{(1.4 \times 10^{19})^2}{1.4 \times 10^{24}} = 1.4 \times 10^{12}$ /m³ ANS

Ratio of electron to hale concentration $\frac{n_i}{n_i} = \frac{1.4 \times 10^{24}}{1.4 \times 10^{24}} = 1 \times 10^{12} \text{ Ans}$

Diode Equation

Volt equivalent of temperature = $V_T = k'T/e = T/11600 = 26 \text{ mV} = 0.026 \text{ V}$

 $\eta = 1$ for Germanium

 $\eta = 2$ for Silicon

- 1. The current flowing through a certain p-n junction diode at room temperature when reversed biased is $0.15\mu A$. Determine the current flowing through the diode when the applied voltage is 0.12V.
- 2. A Si diode has reverse saturation current of $2.5\mu A$ at 300k. Find forward voltage for a forward current of 10 mA.

(1) The diode current is given as
$$I = I_0 (e^{V/nV_{L_1}})$$

Large reverse biase current $I \approx I_0 = 0.15 \times 10^{-6} A$
Applied Voltage $V = 0.12V$
 $V_7 = 26 \text{ mV} = 0.026 \text{ V}$ at soon top.

$$T = 0.15 \times 10^{-6} (e^{0.12/0.026})$$

 $T = 15 \mu A$ Ans

$$I = I_0(e^{\sqrt{hV_T}})$$

$$e^{\sqrt{hv_T}} = \frac{0.01}{2.5 \times 10^{-6}} + 1 = 4 \times 10^{3} + 1 = 4001$$

loge 4 0001 ≈ 8.3